

Monterey Office:

1 Lower Ragsdale Drive  
Building 1, Suite 130  
P.O. Box 3140  
Monterey, CA 93942

Voice 831.649.8800  
Facsimile 831.649.8835

THE LAW FIRM OF

LARIVIERE  
GRUBMAN  
& PAYNE

LLP

---

FACSIMILE COVER SHEET

---

TO: Examiner Ron E. Pompey FAX: (703) 746-3919

FROM: May Lin DeHaan DATE: March 5, 2003

RE: U.S. Patent Application Serial No. 09/826,472  
Entitled: "Method of Fabricating a Semiconductor Device Having a  
Nitride/High-K/Nitride Gate Dielectric Stack by Atomic Layer  
Deposition (ALD) (as amended)

CONFIDENTIAL

---

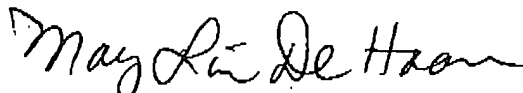
Dear Examiner Pompey:

Please see the attached Informal Response to the outstanding Office Action for your consideration as per our Telephonic Interview of this morning.

As always, if you have any questions or concerns regarding this or any other matter, please do not hesitate to contact us.

Very truly yours,

LARIVIERE, GRUBMAN & PAYNE, LLP



May Lin DeHaan

MLD/pa

THIS TRANSMISSION TOTALS 10 PAGE(S) INCLUDING COVER SHEET